

# **Integrated Circuit Engineering Establishing a Foundation**

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## To my wife

## Preface

Integrated circuits (ICs) occupy a key role in electronics and are to be found in almost every conceivable product of consumer, industrial, and military electronics. They are routinely included in the curriculum of first degrees in electrical/electronic engineering. Many other first degrees in related disciplines like microelectronics and computer engineering also contain substantial material on ICs. The evolution of very-large-scale integration (VLSI) has radically altered the nature of IC engineering. The electronic circuits of a complex system like a computer can now be contained in one or a small number of chips. The nature of VLSI is being brought home to engineers in the form of application-specific ICs (ASICs), which involve customers in their design.

Based on my personal experience of teaching ICs and VLSI on first degrees and on special courses (which I organized) in industry, I perceived the need for a comprehensive text on IC engineering which recognizes the centrality of VLSI, but also embraces lower levels of integration. There is at present a serious gap in such literature. Nothing has been published since 1977 to compare with the comprehensive texts on IC engineering by Hamilton and Howard (1975) and Glaser and Subak-Sharpe (1977). The many books on ICs which have appeared during the last twenty years are generally pitched at a graduate rather than an undergraduate level and tend to be specialized, covering subjects like MOS ICs, VLSI, and IC technology.

This book gives a broad, comprehensive coverage of ICs, embracing fabrication, circuit techniques, and VLSI/ASIC system aspects. Technology is likewise covered in breadth by including bipolar, MOS, and GaAs ICs. It is assumed that readers will have a background in basic transistor operation, analogue and digital circuit practice, and digital design. Alternatively undergraduates may be taught these subjects in parallel with the contents of this book, which is aimed at the second and third years of a British, and the second, third and fourth years of an American degree. The text also meets a vital need for continuing education. Much of the subject matter it contains will probably be new to most engineers and scientists who have graduated some years ago. For that reason this book should prove to be very attractive for career–long learning.

Coming to the details of the contents, the text begins with a general survey (Chapter 1). Device fabrication and packaging (Chapter 2) come next. Chapter 3 covers the formation of transistors, resistors and capacitors, and Chapter 4 outlines device behaviour and modelling. Circuit techniques form the subjects of Chapter 5 (digital) and Chapter 6 (analogue). The last few years have seen a distinct swing towards more analogue and mixed-mode (analogue and digital) ICs, brought about largely by the growth in telecommunications. That situation is reflected

in the contents of Chapter 6, the largest chapter in the book, and the inclusion of mixed-mode ASICs in Chapter 10. Chapter 7 on semiconductor memories initiates the VLSI/ASIC sector, which extends to the end of the book. An overview of ASIC design styles in Chapter 8 paves the way for a fuller treatment of ASICs in Chapters 9 to 11. Chapter 9 describes programmable logic devices (PLDs) with a strong emphasis on field programmable gate arrays (FPGAs). Chapter 10 deals with the characteristics and design issues of ASICs, including economics and design for testability, and Chapter 11 covers ASIC design techniques. Finally Chapter 12 looks at submicron scaling and projections of ICs for the immediate future. Electronics abounds with acronyms and jargon, which are defined in a glossary at the end of the text for ease of reference.

The style of presentation departs in a number of ways from the orthodoxy found in the majority of books on ICs. My first and foremost consideration has been to highlight the engineering dimension. Many publications within the last two decades on the teaching of engineering have urged the need for more material on engineering practice and design, and less on analysis (ASEE 1987; Finniston 1980). Inspite of this there is a continuing trend towards a concentration on analysis.

The roles of analysis and synthesis in this book embody some ideas which I advanced at two conferences in the US (Herbst 1987 and 1989). Analysis has been greatly reduced relative to the traditional presentation in many established texts on ICs. Second synthesis has been carefully structured to illustrate current engineering practice. Last synthesis is often placed before analysis, frequently in the form of an overview at the beginning of a chapter. My approach bears some resemblance to the inverted curriculum proposed by Cohen (1987 and 1992). Extensive quotations of IC specifications and performance bring home the capabilities of current ICs, and this information is continually interwoven with the rest of the text, sometimes even within the analytical sections. The profuse quotations of current IC performance are open to the charge that such material will soon become dated. There is a characteristic American saying that if a piece of equipment works it is out of date. However the probable changes in the performance of future ICs, mainly due to continuing miniaturization, are dealt with, and readers should be able to appreciate the capabilities of new products emerging within the next few years without undue difficulty (Mead and Conway 1980).

The accent on engineering design and applications in this text is long overdue. Much of the engineering science and mathematics of an engineering undergraduate curriculum is unnecessary and can be eliminated, making way for material on synthesis, design and applications (Finniston 1980, pp.94–5). Nevertheless a balance must be maintained between analysis and synthesis: the danger of overemphasizing the engineering aspects to the detriment of fundamental concepts is very real.

Muller and Kamins (1986) hold successful engineering to rest on two foundations, physical concepts and technology. Zorpette (1984) warns against excessive emphasis on what he calls the technology of the moment. Everitt (1980) defined the fundamental difference between science and engineering to be the difference between analysis and synthesis, and went on to say that synthesis can only be accomplished after a thorough grounding in analysis. G.M. Trevelyan (1946), the late great English his-

It remains for me to express my gratitude for the help I have received from various sources. Apart from obtaining databooks from semiconductor vendors, I had countless conversations with staff from these establishments to clear up matters on which I felt uncertain, or to obtain additional information. This help was given most willingly without exception and has been of tremendous value. The manuscript has been produced and typeset with the aid of computer typesetting software by Trevor and Rose Atkinson, who have very effectively accommodated special requirements regarding style and have been most helpful throughout. I am indebted to Colin Gregg, who has drawn all the diagrams with the aid of computer graphics, and has in many cases improved on the originals submitted to him. The help and cooperation of the publishers at all stages of the production is gratefully acknowledged.

Last and most I am indebted to my wife for her unstinting support for this undertaking, which made a severe inroad on the time for normal domesticity. It is only her encouragement and understanding which have made this book possible.

Middlesbrough September 1995 L.J.H.

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On a more general note, the author advises that the quotations of data from the establishments listed are only guidelines, but that fuller information, sometimes going beyond what is available in databooks and datasheets, should be consulted for actual designs.

# Contents

1	Overview		
	1.1	IC structure	1
	1.2	Historical perspective	4
	1.3	IC spectrum	8
		1.3.1 VLSI	8
		1.3.2 SSI and MSI	9
		1.3.3 PLDs	10
		1.3.4 Analogue ICs	10
		1.3.5 ASICs	11
		1.3.6 Summary	12
		References	13
2	Fab	rication and packaging	15
	2.1	Processing outline	15
	2.2	Processing sequence for transistors	18
	2.3	Wafer preparation	22
	2.4	Deposition and growth	25
		2.4.1 Oxidation	25
		2.4.2 Epitaxy	30
		2.4.3 Diffusion	31
		2.4.4 Ion implantation	34
		2.4.5 Dielectric and polysilicon films	39
		2.4.6 Interconnects	40
	2.5	0 1 0	44
		2.5.1 Introduction	44
		2.5.2 Lithographic technology	44
		2.5.3 Resists	50
	0.0	2.5.4 Etching	52
	2.6		56
		2.6.1 Introduction	56 57
		<ul><li>2.6.2 Packages available</li><li>2.6.3 Packaging and mounting technologies</li></ul>	57 59
		2.6.4 Package selection	63
		2.6.5 Multichip modules	65
	2.7	Overview	67
		References	69
3	Component formation		73
	3.1	Introduction	73
	3.2	CMOS	73
	3.3	Silicon bipolar transistors	78

	3.4	BiCMOS	81
	3.5	GaAs transistors	82
	3.6	Resistors and capacitors	84
	3.7	Design rules and device areas	87
		References	91
4	De	vice behaviour and modelling	93
	4.1	Introduction	93
	4.2	Transient response and bandwidth	93
	4.3	MOSFET characteristics	96
		4.3.1 DC characteristics	96
		4.3.2 Capacitances	100
		4.3.3 Channel transit time	103
		4.3.4 Hot carriers	103
		GaAs MESFET characteristics	103
	4.5		105
	4.6	The role of SPICE	109
	4.7		111
		4.7.1 Introduction	111
		4.7.2 MOSFET models	111
		4.7.3 GaAs MESFET model	112
		4.7.4 BJT model 4.7.5 Junction diode	112
		References	112
			113
		Further reading	114
5		ital circuits — techniques and performance	117
	5.1	Introduction	117
	5.2	Logic Circuits	117
		5.2.1 Design criteria	117
		5.2.2 Overview of logic familes 5.2.3 nMOS	118
		5.2.4 CMOS	119
		5.2.5 ECL/CML	$\frac{121}{129}$
		5.2.6 TTL	132
		$5.2.7   I^2L$	135
		5.2.8 BiCMOS	138
		5.2.9 GaAs	141
	5.3	Bistables	145
	5.4	Dynamic CMOS	150
	5.5	Survey of logic circuits	152
		5.5.1 Overview	152
		5.5.2 Characterization and performance	157
		5.5.3 Comparison of GaAs with Si	172
		Appendix—SPICE parameters	175
		References	177
		Further reading	179

6	Ana	alogue circuits—techniques and performance	181
	6.1	Introduction	181
	6.2	Operational amplifiers	181
		6.2.1 Basic concepts	181
		6.2.2 Circuit techniques	186
		6.2.3 Specification and performance	194
	6.3	Voltage comparators	206
	6.4	Voltage references and regulators	209
		6.4.1 Voltage references 6.4.2 Voltage regulators	209 215
	c r		213
	6.5	Analogue signal processing 6.5.1 Introduction	224
		6.5.2 Analogue filters	226
		6.5.3 ADCs	232
		6.5.4 DACs	242
		6.5.5 Specification and performance	244
		6.5.6 Oversampling sigma–delta converters	249
		References	258
		Further reading	260
7	Semiconductor memories		261
	7.1	Introduction	261
	7.2	Organization and operation	263
	7.3	SRAMs	267
	7.4	DRAMs	271
	7.5	ROMs	277
	7.6	Characterization and performance	284
		References	290
		Further reading	291
8	ASIC design styles		293
	8.1	Introduction	293
	8.2	Categories	293
	8.3	Gate arrays	294
	8.4	Standard cells	296
	8.5	Cell-based ASICs	297
	8.6	Mixed-mode and analogue ASICs	298
	8.7	PLDs	298
		8.7.1 PLA and PAL	298
		8.7.2 Field programmable gate arrays	300
	8.8	Overview	301
		Further reading	302
9	ASI	Cs—Programmable logic devices	303
	9.1	Overview	303
	9.2	PAL-based PLDs	304
		9.2.1 Structures	304

		9.2.2 PAL characteristics	313
	9.3	FPGAs	318
		9.3.1 Introduction	318
		9.3.2 Selected families	319
	9.4	Design outline	332
		References	336
		Further reading	337
10	AS	Cs—Characteristics and design issues	339
	10.1	Introduction	339
	10.2	Design methodology and design tools	342
	10.3	Design for testability	344
	10.4	Economics	356
	10.5	Characteristics and performance	362
		10.5.1 Design styles	362
		10.5.2 Gate arrays	365
		10.5.3 Standard cells 10.5.4 Cell-based ASICs	370
		10.5.4 Cen-based ASICs 10.5.5 Mixed-mode and analogue ASICs	371
	10.6	Overview	372 380
		References	383
		Further reading	384
11	A CIT	0	
11		Cs—Design techniques Overview	385
	_		385
		Design flow and methodology	387
		Hardware description languages	398
		Simulation and checking	406
		Commercial design tools	409
		FPGA design tools	417
	11.7	Conclusions References	419
			421
		Further reading	423
<b>12</b>		micron scaling	425
		Overview	425
	12.2	MOSFET scaling	431
		BJT scaling	437
	12.4	Interconnection scaling	439
	12.5	The immediate future	444
		References	449
	Glos	sary	453
	Inde	x	465

### Overview

#### 1.1 IC structure

The nature of electronic equipment based on integrated circuits (ICs) is illustrated in Fig. 1.1, the photograph of a motherboard, a printed circuit board (PCB) for a personal computer (PC). The motherboard is the core of the electronics for the computer. It contains numerous ICs of various types and sizes, in addition to a few discrete components (resistors, capacitors, crystal oscillators), and sockets for interconnecting the motherboard to other PCBs. The ICs have transistor counts ranging from about 100 to 250 000 per package, and are interconnected to form a highly sophisticated system. The complexity of an IC in this era of very-large-scale integration (VLSI) is evident from the photograph in Fig. 1.2, which shows the surface of a die (signifying an unencapsulated chip). That die contains over 100 000 transistors, has 68 bonding pads, and measures about  $8\times 8~\text{mm}^2$ . It is encapsulated in a 68-pin square package not much larger than the die. This section presents a very brief outline of the structure and the processing leading to an IC.

Figure 1.3 shows the profile of a die. The electrodes of all active (transistors and diodes) and passive (resistors and capacitors) components are

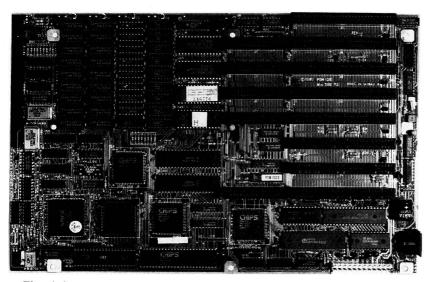


Fig. 1.1 PC motherboard photograph (Courtesy of Opus Technology)